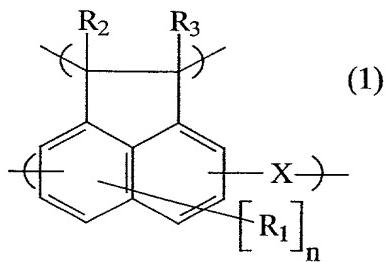


ABSTRACT OF THE DISCLOSURE

An anti-reflection coating-forming composition is provided. This composition includes a polymer and a solvent. The polymer
5 has a structural unit represented by the formula (1):



wherein R₁ is a monovalent atom other than a hydrogen atom or a monovalent group, and n is an integer of 0-4, provided that when n is an integer of 2-4, a plural number of R₁'s are the same or
10 different; R₂ and R₃ are each a monovalent atom or group; and X is a bivalent group. The anti-reflection coating formed from this composition has a high antireflective effect, does not generate intermixing with a resist film, and enables a good resist pattern profile excellent in resolution and precision in
15 cooperation with a positive or negative resist.